

Technology Development Status of Adjustable Grazing Incidence X-ray Optics

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Summary Status: Refresher from Aug. '12

- PENN<u>State.</u>
- Demonstrated good agreement between modeled and measured influence functions on flat test optics
- Improved yield on test flats to > 95 per cent (good piezo cells)
- Modeling with representative figure errors from mounted mirrors consistent with half arc sec HPD post correction.
- Claimed TRL 2
- Just started work on curved segments
 - Uniform deposition
 - Printing electrode pattern
- Incorporating optical profilometer

Summary Status: New Since Aug. '12



- Improved yield on flat mirrors to routinely 100 per cent
 - I.e., all piezo cells good
- PZT deposition development essentially complete
- Incorporated new metrology
 - Lower noise than before and faster, but not meeting our expectation
- Response uniformity meets requirements (+/- 30 per cent)
- Repeatability within metrology noise (20 nm, rms)
- Fabrication and testing of cylindrical test mirrors
 - Influence functions match models to within metrology noise
 - Piezo coefficient same (within errors) to flat pieces
- Believe now at TRL3

Flat sample repeatability and uniformity



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Hysteresis curves for all 33 actuators on 10 cm diameter flat test sample.

Flat sample: multiple piezo cells



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Energized 6 piezo cells in a row – all at same 10V. Measured profile matches modeled profile to within 40 nm, rms.

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Cylindrical sample





Right: same sample as above, mounted to cylindrical optic metrology mount, on scanning optical profilometer

CHNI-TOOL 3 400PR110

Repeatability and gain on cylindrical test piece 🗦

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Hysteresis curves.

Cylindrical segment: repeatability



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Expanded plot of hysteresis curves for cylindrical test mirror. Numbers on right represent order in which the hysteresis curves were measured. Repeatability = 20 nm, rms, equal to metrology noise for test,

Cylindrical test mirror: influence functions





Axial Position (mm)

Comparison of modeled and measured influence functions for cylindrical test mirror (4V). Difference between model and measurement is 11.4 nm, rms – metrology repeatability ~ 20 nm rms

Other activities



Accelerated lifetime testing

- Examining effects of Nb dopants
- Refining parameters for accelerated lifetime testing scaling with voltage and temperature
- Current estimates, not including area scaling, ridiculously long (thousand of years)
- Modeling/optimization
 - Simulation of different size and shape piezo cell layouts
 - Interleaved layout yields best result
 - Ellipsoidal shaped cells and 5 mm electrodes on 10 mm spacing give poorer result than nominal square array
 - Piezo voltage optimization with bounds and constraints
 - Bounded constrained least squares
 - Non-negative least squares

Small piezo cell modeling (ZnO program)

- PENN<u>State.</u>
- Nominal piezo cell sizes (1 mm gaps between cells)
 - 10 mm x 10 mm for development optics
 - 10 mm x 20 mm (L × W) for SMART-X simulations
- New, small size piezo cell modeling
 - For SMART-X simulations
 - 4.8 mm x 9.8 mm with 0.2 mm gaps
 - 0.9 mm x 0.9 mm with 0.1 mm gaps
 - Also looking at:
 - Error correction bandwidth
 - Potential for redundant sets of adjusters
 - Error correction amplitude range

Simulation Results – I

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Simulation Results – II



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NX I-deas 6.1 : Central Engineering IDEAS 12 Team HT (cel) : wdavis : D:\NX-6

I cell x {I0 x 20} 0.56 um/I00 ppm

10 x 20 cells x {1 x 1} 0.5 um/100 ppm

Simulation Results – III



- $5 \times 10 \text{ mm}^2$ cells give slightly better (few percent) corrected residual than $10 \times 20 \text{ mm}^2$ cells, using exemplar data
 - Relatively low spatial frequency errors
 - Will compute an effective piezo cell correction 'filter efficiency'
 - Error correction as a function of spatial error frequency
- 5 x 10 mm² cells have slightly lower amplitude correction range than 10 x 20 mm² cells
 - Larger strain required to correct exemplar data

Simulation Results – IV



0.8

0.6

0.4

0.2

-0.4

1.6

1.4

1.2

1.0

- 0.8

0.6

0.4

0.2

0.0

0.8

0.6

0.4

0.2

0.0

-0.2

-0.6

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$10 \times 20 \text{ mm}^2 \text{ cells}$



Bias flat (ampl=0.4)

Bias flat (ampl=0.4)



-0.016

-0.024

-0.032

-0.040

0.420

0.415

0.410

0.405

0.400

0.395

0.390

0.385

0.380

0.030

0.015

0.000

-0.015

-0.030

-0.045

-0.060

0.420

0.415

0.410

0.405

0.400



Displ-X exemplar data (ampl=1.00)





$5 \times 10 \text{ mm}^2$ cells









- Independently addressable piezo cells.
- Voltage across top electrode and bottom electrode produces strain in piezo in plane of mirror surface, resulting in localized bending.
- Optimizing the piezo voltages *after* mirror mounting enables correction of fabrication errors *and* mounting-induced deformations.
- Calibrated on-cell strain gauges provide feedback on cell strain/deformation, enable mirror figure corrections to be made on-orbit.

Other activities



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• Real time lifetime testing

- mask and fixturing designed, being fabricated
- Incorporate strain gauges directly on piezo cell
 - Need to test/calibrate, but estimated strain accuracy is +/- I part per million (ppm), compared to nominal strains of ~ 500 ppm





Flat test mirror with strain guages



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Summary



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• We continue to make progress.

- Claim current TRL = 3
 - Measurements match models on curved mirror segments
 - Measurements repeatable to metrology noise levels
 - Models suggest correction of 7 10 arc sec mounted mirrors to sub-arc sec level
 - PZT deposition process developed
- Plan for full aperture X-ray test of mounted, aligned, corrected conical pair in late FY15
 - TRL 4
- Separate development contract (PSU PI, SAO Co-I) for ZnO integrated electronics